IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :

Woon-kyung LEE et al.

Attn: Applications Branch

Serial No.: [NEW]

Attorney Docket No.: SEC.697D

Filed: 17 November 2003

For:

MASK ROM FABRICATION METHOD

CLAIM OF PRIORITY

U.S. Patent and Trademark Office 2011 South Clark Place **Customer Window** Crystal Plaza Two, Lobby, Room 1B03 Arlington, VA 22202

Sir:

Applicant, in the above-identified application, hereby claims the priority date under the International Convention of the following Korean application:

Appln. No. 1999-16605

filed May 10, 2000

as acknowledged in the Declaration of the subject application.

A certified copy of said application was submitted in the parent application.

Respectfully submitted,

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Dated: 17 November 2003

대 한 민 국 특 허 청 KOREAN INDUSTRIAL PROPERTY OFFICE

별첨 사본은 아래 출원의 원본과 동일함을 증명함.

This is to certify that the following application annexed hereto is a true copy from the records of the Korean Industrial Property Office.

출 원 번 호 : 1999년 특허출원 제16605호

Application Number

출 원 년 월 일 : 1999년 5월 10일

Date of Application

출 원 인 : 삼성전자 주식회사

Applicant(s)



1999 년 5월 28일

특 허 청 COMMISSIONER

